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APPARATUS AND METHOD OF
MANUFACTURING THE SAME**(30) **Foreign Application Priority Data**

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USPC **257/40**(73) Assignee: **Samsung Display Co., Ltd.**, Yongin-si
(KR)(57) **ABSTRACT**(21) Appl. No.: **14/191,784**(22) Filed: **Feb. 27, 2014****Related U.S. Application Data**(62) Division of application No. 13/443,767, filed on Apr.
10, 2012, now Pat. No. 8,697,468.

An organic light-emitting apparatus includes a substrate; a first electrode formed on the substrate, where the first electrode is a cathode, an electron injection layer formed to contact an upper surface of the first electrode and including Mg, an intermediate layer formed on the electron injection layer and including an organic emission layer, and a second electrode which is formed on the intermediate layer and is an anode.

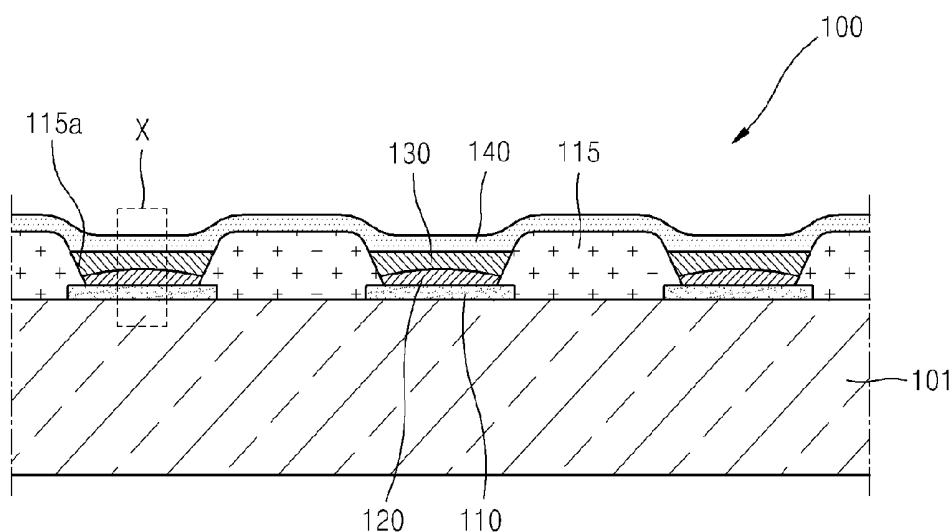


FIG. 1

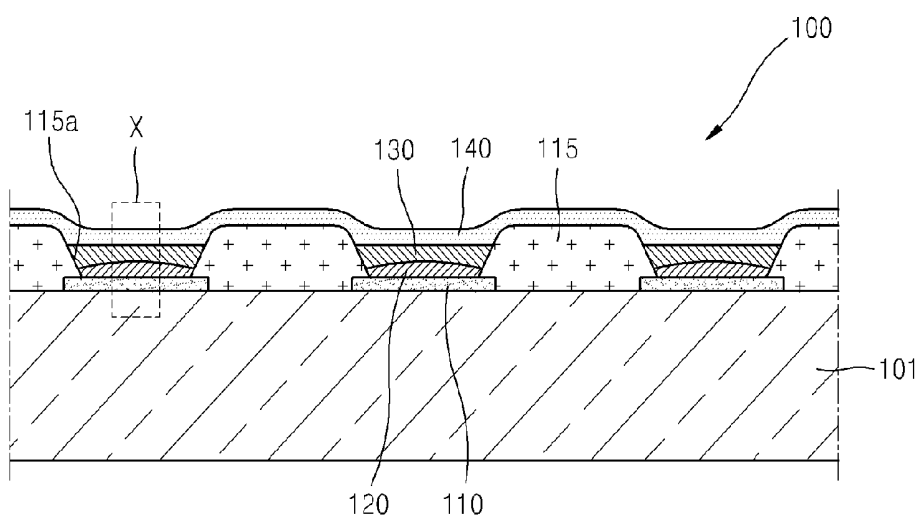


FIG. 2

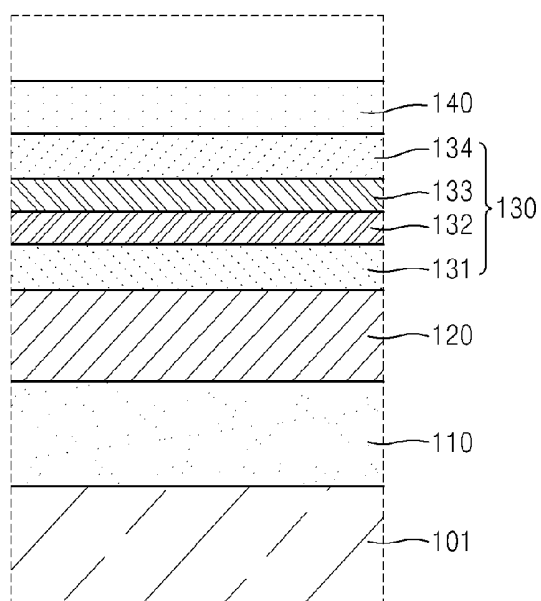


FIG. 3

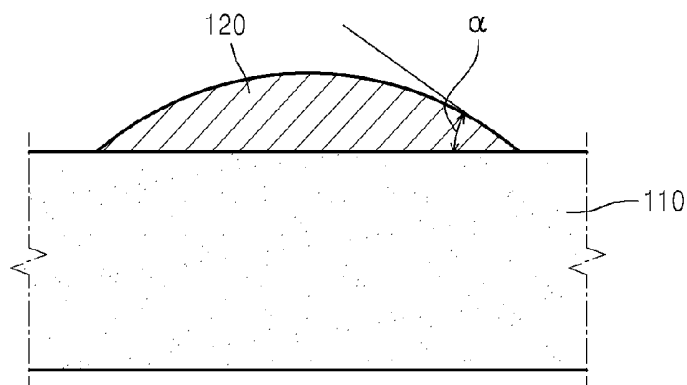


FIG. 4

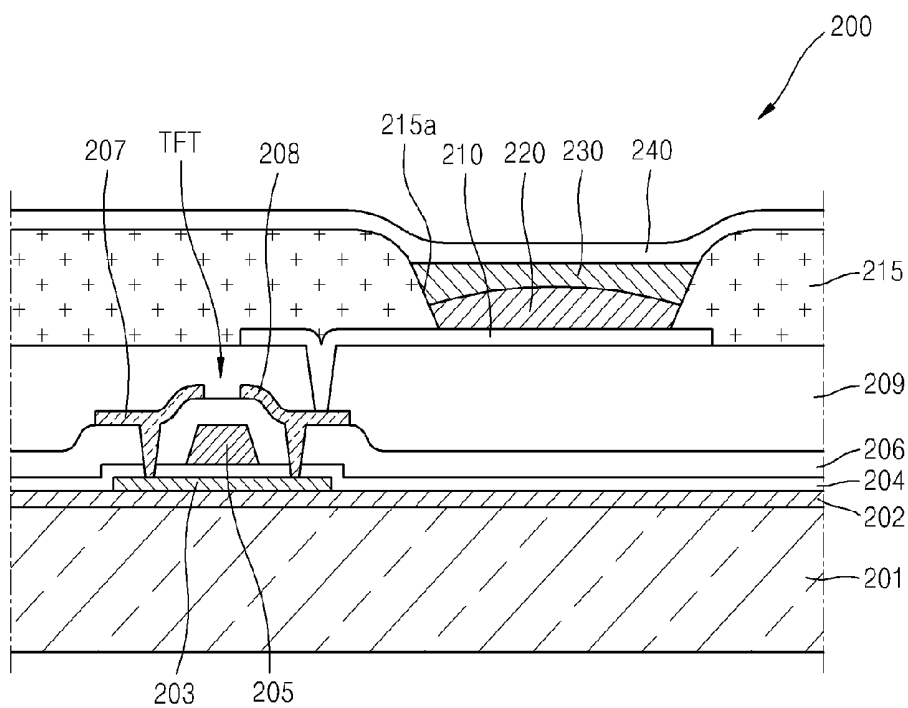


FIG. 5A

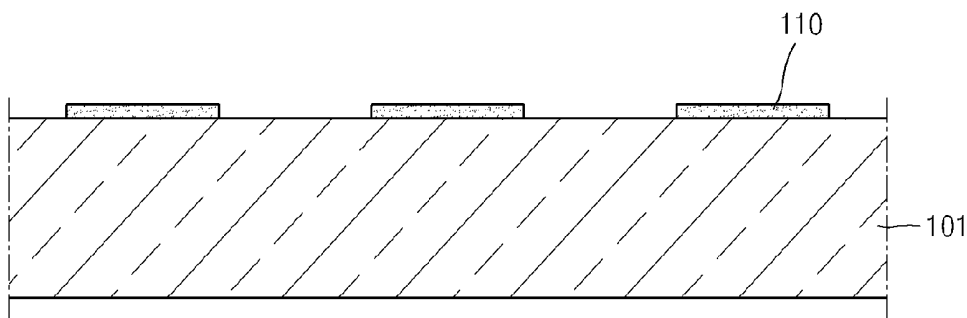


FIG. 5B

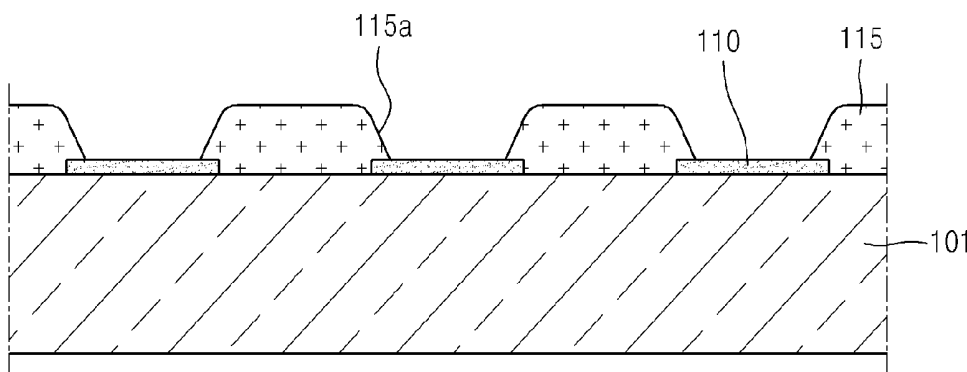


FIG. 5C

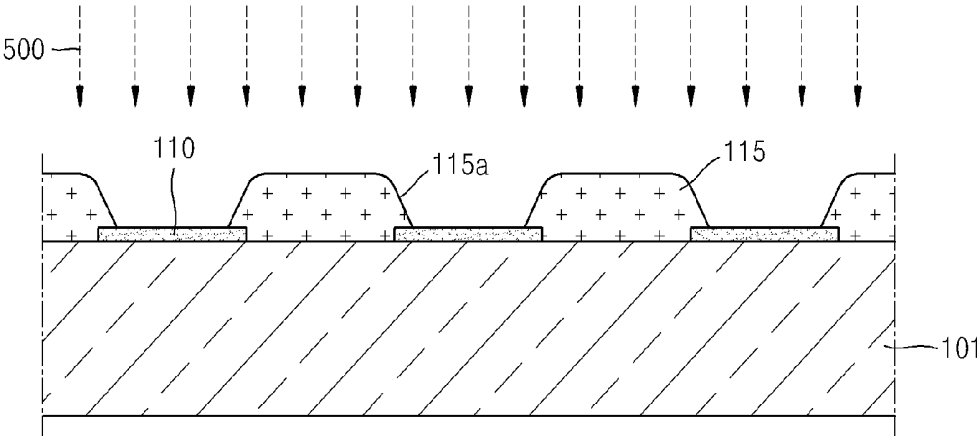


FIG. 5D

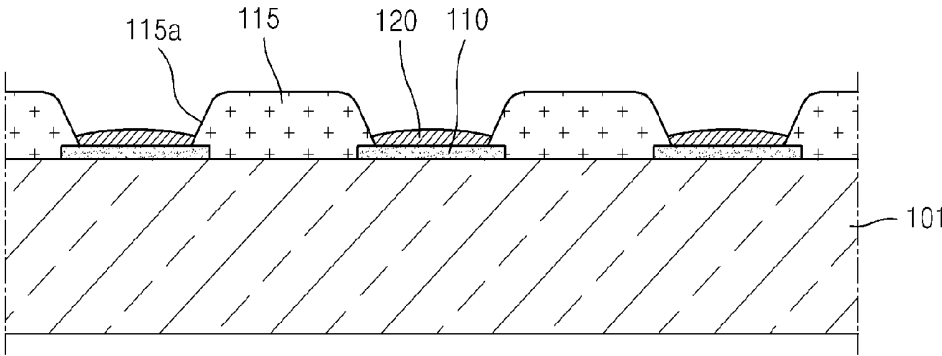
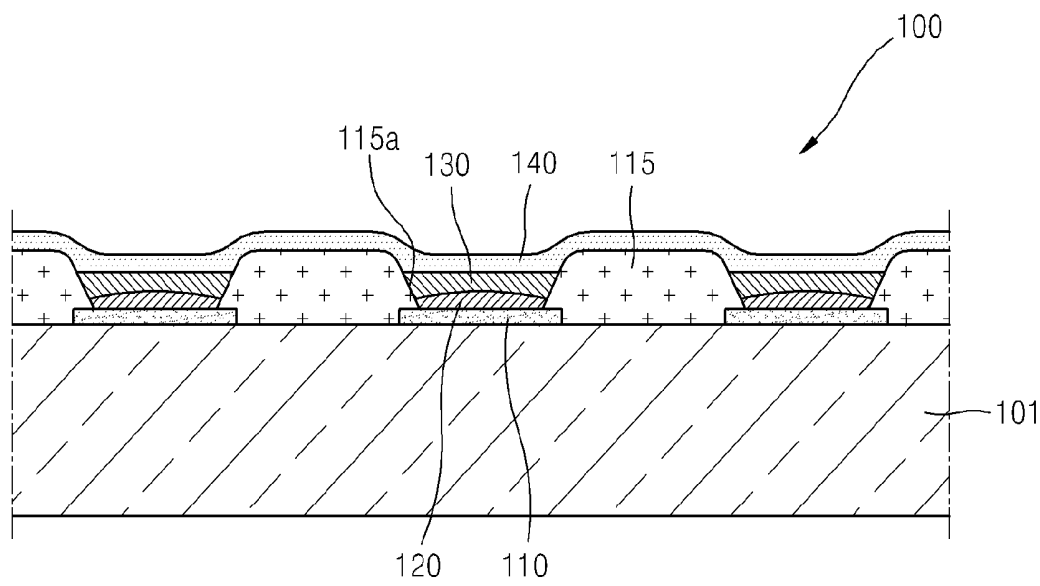


FIG. 5E



ORGANIC LIGHT-EMITTING DISPLAY APPARATUS AND METHOD OF MANUFACTURING THE SAME

CROSS-REFERENCE TO RELATED APPLICATIONS

[0001] This application claims priority to U.S. patent application Ser. No. 13/443,767, filed on Apr. 10, 2012, titled "Organic Light-Emitting Display Apparatus And Method Of Manufacturing The Same", which claims the benefit of Korean Patent Application No. 10-2011-0068964, filed on Jul. 12, 2011, the disclosures of which are hereby incorporated herein by reference in their entireties.

BACKGROUND

[0002] 1. Field

[0003] The present disclosure relates to an organic light-emitting apparatus for improving image quality and a method of manufacturing the same.

[0004] 2. Description of the Related Technology

[0005] Recently, display apparatuses have been replaced with thin-film type flat panel display apparatuses that are portable. From among thin-film type flat panel display apparatuses, an organic light-emitting display apparatus is a self-emitting display apparatus, has a larger viewing angle, better contrast characteristics, and a faster response rate, and thus has drawn attention as a next-generation display device.

[0006] An organic light-emitting display apparatus includes a first electrode, a second electrode, and an intermediate layer. The intermediate layer includes an organic emission layer. When voltage is applied to the first electrode and the second electrode, the organic emission layer emits visible light.

[0007] However, an optical efficiency of the organic emission layer is limited, and thus improving image quality of the organic light-emitting display apparatus is limited.

SUMMARY OF CERTAIN INVENTIVE ASPECTS

[0008] Embodiments provide an organic light-emitting apparatus for improving image quality and a method of manufacturing the same.

[0009] According to one aspect, there is provided an organic light-emitting apparatus including: a substrate; a first electrode which is formed on the substrate and is a cathode; an electron injection layer formed to contact an upper surface of the first electrode and including Mg; an intermediate layer formed on the electron injection layer and including an organic emission layer; and a second electrode which is formed on the intermediate layer and is an anode.

[0010] A contact angle between the electron injection layer and the first electrode can be in the range of 10° to 70°.

[0011] The first electrode can include indium tin oxide (ITO).

[0012] The organic light-emitting apparatus can further include a pixel defining layer disposed on the first electrode and including an opening, wherein the electron injection layer and the first electrode each other contact in the opening.

[0013] The electron injection layer can be disposed in the opening so as not to deviate from the opening.

[0014] The pixel defining layer can include a polymer material.

[0015] According to another aspect, there is provided a method of manufacturing an organic light-emitting apparatus,

the method including: forming a first electrode, which is a cathode, on a substrate; forming an electron injection layer including Mg so as to contact an upper surface of the first electrode; forming an intermediate layer including an organic emission layer on the electron injection layer; and forming a second electrode, which is an anode, on the intermediate layer.

[0016] The forming of the electron injection layer can be performed in such a way that a contact angle between the electron injection layer and the first electrode is in the range of 10° to 70°.

[0017] Plasma treatment can be performed between the forming of the first electrode and the forming of the electron injection layer.

[0018] The plasma treatment can be performed using nitrogen or oxygen.

[0019] The plasma treatment can be performed under a pressure of 30 mmTorr to 100 mmTorr and a power atmosphere of 200 W to 1000 W.

[0020] The plasma treatment can be performed for 30 to 300 seconds.

[0021] The method can further include forming a pixel defining layer between the forming of the first electrode and the forming of the electron injection layer, wherein the pixel defining layer is formed on the first electrode and comprises an opening corresponding to the first electrode, wherein the plasma treatment is performed between the forming of the pixel defining layer and the forming of the electron injection layer, and the electron injection layer is formed in the opening so as not to deviate from the opening.

[0022] Ultra violet (UV) treatment can be performed between the forming of the first electrode and the forming of the electron injection layer.

[0023] The UV treatment can be performed under a normal pressure.

[0024] The UV treatment can include ozone.

[0025] The UV treatment can be performed for 10 to 60 seconds.

[0026] The method can further include forming a pixel defining layer between the forming of the first electrode and the forming of the electron injection layer, wherein the pixel defining layer is formed on the first electrode and comprises an opening corresponding to the first electrode, wherein the UV treatment is performed between the forming of the pixel defining layer and the forming of the electron injection layer, and the electron injection layer is formed in the opening so as not to deviate from the opening.

[0027] The forming of the first electrode can be performed using ITO.

BRIEF DESCRIPTION OF THE DRAWINGS

[0028] The above and other features and advantages of the present invention will become more apparent by describing in detail certain embodiments thereof with reference to the attached drawings in which:

[0029] FIG. 1 is a schematic cross-sectional view illustrating an embodiment of an organic light-emitting apparatus;

[0030] FIG. 2 is an enlarged view of region X illustrated in FIG. 1;

[0031] FIG. 3 is a schematic view of a contact angle between a first electrode and an electron injection layer illustrated in FIG. 1;

[0032] FIG. 4 is a schematic cross-sectional view illustrating another embodiment of an organic light-emitting apparatus; and

[0033] FIGS. 5A through 5E are cross-sectional views sequentially illustrating an embodiment of a method of manufacturing an organic light-emitting apparatus.

DETAILED DESCRIPTION OF CERTAIN INVENTIVE EMBODIMENTS

[0034] Certain embodiments will be described in detail with reference to the accompanying drawings.

[0035] FIG. 1 is a schematic cross-sectional view illustrating an embodiment of an organic light-emitting apparatus 100.

[0036] Referring to FIG. 1, the organic light-emitting apparatus 100 includes a substrate 101, a first electrode 110, an electron injection layer 120, an intermediate layer 130, and a second electrode 140.

[0037] The substrate 101 can be formed of a SiO₂-based transparent glass material, but is not limited thereto and can be formed of any transparent plastic material. The transparent plastic material can be an insulating organic material, for example, at least one material selected from the group consisting of polyethersulphone (PES), polyacrylate (PAR), polyetherimide (PEI), polyethylenenaphthalate (PEN), polyethyleneterephthalate (PET), polycontact angle α ene sulfide (PPS), polyallylate, polyimide, polycarbonate (PC), cellulose triacetate (TAC), and cellulose acetate propionate (CAP).

[0038] The substrate 101 can be formed of a metal, or it can be in the form of foil.

[0039] The first electrode 110 is disposed on the substrate 101. The first electrode 110 can be formed with a predetermined pattern by using a photolithography method. A buffer layer (not shown) may be formed between the substrate 101 and the first electrode 110 so as to provide a flat surface on the substrate 101 and to prevent impurities from penetrating the substrate 101. The buffer layer can be formed of SiO₂ and/or SiNx.

[0040] The pattern of the first electrode 110 can be formed of a plurality of stripe lines that are spaced apart from one another at a predetermined interval. Some embodiments of the organic light-emitting apparatus 100 can be a passive matrix (PM)-type organic light-emitting apparatus. An active matrix type (AM) organic light-emitting apparatus is described below.

[0041] The first electrode 110 functions as a cathode, and includes indium tin oxide (ITO).

[0042] A pixel defining layer 115 is disposed on the first electrode 110. The pixel defining layer 115 includes an opening 115a corresponding to the first electrode 110. The pixel defining layer 115 covers edges of the first electrode 110, and the opening 115a overlaps with a predetermined region of an upper surface of the first electrode 110. The pixel defining layer 115 can be formed of any of various insulating materials and can include a high molecular material. The pixel defining layer 115 can include a polyimide-based high molecular material.

[0043] The electron injection layer 120 is disposed on the first electrode 110 to contact the upper surface of the first electrode 110. The electron injection layer 120 is disposed in the opening 115a so as not to deviate from the opening 115a of the pixel defining layer 115 and contacts the upper surface of the first electrode 110. The electron injection layer 120

includes magnesium (Mg) so as to improve an electron injection characteristic into the intermediate layer 130.

[0044] The electron injection layer 120 is disposed to have a contact angle α between about 10° and about 70° when contacting the first electrode 110.

[0045] When the contact angle α between the electron injection layer 120 and the first electrode 110 is less than about 10°, the electron injection layer 120 may be formed not only in the opening 115a of the pixel defining layer 115, but also in the entire area of the pixel defining layer 115. One opening 115a of the plurality of openings 115a illustrated in FIG. 1 may correspond to one sub-pixel. When the contact angle α between the electron injection layer 120 and the first electrode 110 is less than about 10°, the electron injection layer 120 may be formed to extend across all the openings 115a.

[0046] In such a case, there may be a problem in that all sub-pixels (not shown) are short-circuited due to the electron injection layer 120. Accordingly, it is preferable that the contact angle α between the electron injection layer 120 and the first electrode 110 is equal to or greater than about 10°.

[0047] When the contact angle α between the electron injection layer 120 and the first electrode 110 is greater than about 70°, a contact characteristic of a contact surface between the electron injection layer 120 and the first electrode 110, and a contact characteristic of a contact surface between the intermediate layer 130 and the electron injection layer 120 are decreased. Thus, an electric field is not properly applied to the intermediate layer 130, and in particular, to the organic emission layer of the intermediate layer 130, and consequently, an electrical characteristic and image quality of the organic light-emitting apparatus 100 are decreased. Accordingly, the contact angle α between the electron injection layer 120 and the first electrode 110 is equal to or less than about 70°.

[0048] The intermediate layer 130 is disposed on the electron injection layer 120. The intermediate layer 130 includes at least an organic emission layer 132. The intermediate layer 130 also includes an electron transport layer 131, a hole transport layer 133, and a hole injection layer 134.

[0049] The organic emission layer 132 can emit visible light having various colors, such as for example, red, green, and blue.

[0050] When the organic emission layer 132 emits red visible light, the organic emission layer 132 can include tetraphenyl naphthacene (Rubrene), tris(1-phenylisoquinoline) iridium(III) (Ir(piq)₃), bis(2-benzo [b]thiophene-2-ylpyridine)(acetylacetonate)iridium(III) (Ir(btp)₂(acac)), tris(dibenzoylmethane)phenanthroline europium(III) (Eu(dbm)₃(phen)), tris[4,4'-di-tert-butyl-(2,2')-bipyridine]ruthenium(III) complex (Ru(dtb-bpy)₃*2(PF₆)), DCM1, DCM2, Eu(thenoyltrifluoroacetone)₃ (Eu(TTA)₃), butyl-6-(1,1,7,7-tetramethyljulolidyl-9-enyl)-4H-pyran (DCJTb), and the like, and can also include a polymer emission material such as a polyfluorene-based polymer or a polyvinyl-based polymer.

[0051] When the organic emission layer 132 emits green visible light, the organic emission layer 132 can include 3-(2-benzothiazolyl)-7-(diethylamino)coumarin (Coumarin 6) 2,3,6,7-tetrahydro-1,1,7,7-tetramethyl-1H, 5H, 11H-10-(2-benzothiazolyl)quinolidino-[9,9a,1gh]coumarin (C545T), N,N'-dimethyl-quinacridone (DMQA), tris(2-phenylpyridine)iridium(III) (Ir(ppy)₃), and the like, that are green lumi-

nescent materials, and can also include a polymer emission material such as a polyfluorene-based polymer or a polyvinyl-based polymer.

[0052] When the organic emission layer **132** emits blue visible light, organic emission layer **132** can include oxadiazole dimer dyes (Bis-DAPDXP), spiro compounds (Spiro-DPVB, Spiro-6P), triarylamine compounds, bis(styryl) amine (DPVB, DSA), 4,4'-bis(9-ethyl-3-carbazovinylen)-1,1'-biphenyl (BCzVBi), perylene, 2,5,8,11-tetra-tert-butylperylene (TPBe), 9H-carbazole-3,3'-(1,4-phenylene-di-2,1-ethene-diyl)bis[9-ethyl-(9C)] (BCzVB), 4,4-bis[4-(di-p-tolylamino)styryl]biphenyl (DPAVB), 4-(di-p-tolylamino)-4'-[(di-p-tolylamino)styryl]stilbene (DPAVB), 4,4'-bis[4-(diphenylamino)styryl]biphenyl (BDAVB), bis(3,5-difluoro-2-(2-pyridyl)phenyl-(2-carboxypyridyl)iridium III (FlrPic), and the like, that are blue luminescent materials, and can also include a polymer emission material such as a polyfluorene-based polymer or a polyvinyl-based polymer.

[0053] Other embodiments of the organic emission layer **132** can be formed of any of various materials.

[0054] The electron transport layer **131** is disposed on the electron injection layer **120**, the organic emission layer **132** is disposed on the electron transport layer **131**, the hole transport layer **133** is disposed on the organic emission layer **132**, and the hole injection layer **134** is disposed on the hole transport layer **133**.

[0055] In other embodiments, the intermediate layer **130** may include one or two of the electron transport layer **131**, the hole transport layer **133**, and the hole injection layer **134** instead of including all of them. In yet other embodiments, the intermediate layer **130** may include only the organic emission layer **132**.

[0056] The second electrode **140** is disposed on the intermediate layer **130**. The second electrode **140** functions as an anode. When the organic light-emitting apparatus **100** is a PM-type organic light-emitting apparatus, the second electrode **140** can be in the form of stripe crossing the pattern of the first electrode **110** at right angles.

[0057] The second electrode **140** can be a reflective electrode or a transmissive electrode. When the second electrode **140** is a reflective electrode, the second electrode **140** is formed by forming a reflective layer including silver (Ag), Mg, aluminum (Al), platinum (Pt), palladium (Pd), gold (Au), nickel (Ni), neodymium (Nd), iridium (Ir), chromium (Cr), lithium (Li), calcium (Ca), or a combination thereof and disposing ITO, indium zinc oxide (IZO), zinc oxide (ZnO), or In_2O_3 having a high work function thereon.

[0058] When the second electrode **140** is a transmissive electrode, the second electrode **140** is formed of ITO, IZO, ZnO, or In_2O_3 having a high work function.

[0059] A sealing member (not shown) may be disposed on the second electrode **140** so as to be opposite to a surface of the substrate **101**. The sealing member (not shown) can be formed to protect the intermediate layer **130** against external moisture or oxygen and can be formed of glass or plastic, or alternatively, of a plurality of stacked structures each including an organic material and an inorganic material.

[0060] In some embodiments, the organic light-emitting apparatus **100** includes the electron injection layer **120** including Mg and thus can easily implement an inverted type having an improved electron injection characteristic. In particular, when the first electrode **110** is a cathode including ITO having a relatively high work function, an electron injection characteristic can be decreased. However, since the elec-

tron injection layer **120** including Mg is formed to contact the first electrode **110**, an electron injection characteristic into the intermediate layer **130** through the first electrode **110** is not decreased.

[0061] Also, the contact angle α between the electron injection layer **120** and the first electrode **110** can be in the range of about 10° to about 70° , so that a short circuit of sub-pixels due to the electron injection layer **120** may be prevented and image quality of the organic light-emitting apparatus **100** may be improved by increasing a contact characteristic of a contact surface between the electron injection layer **120** and the first electrode **110** and a contact characteristic of a contact surface between the intermediate layer **130** and the electron injection layer **120**.

[0062] FIG. 4 is a schematic cross-sectional view illustrating another embodiment of an organic light-emitting apparatus.

[0063] Referring to FIG. 4, an organic light-emitting apparatus **200** includes a substrate **201**, a thin film transistor (TFT), a first electrode **210**, an electron injection layer **220**, an intermediate layer **230**, and a second electrode **240**. The TFT includes an active layer **203**, a gate electrode **205**, a source electrode **207**, and a drain electrode **208**.

[0064] Hereinafter, components of each member will be described in detail.

[0065] A buffer layer **202** is formed on the substrate **201**. The buffer layer **202** can include SiO_2 or SiN_x . The buffer layer **202** can also have a structure in which a plurality of layers are stacked. The buffer layer **202** provides a flat surface on the substrate **201** and prevents moisture or foreign substances from penetrating the substrate **201**.

[0066] The active layer **203** having a predetermined pattern is formed on the buffer layer **202**. The buffer layer **202** can be formed of an organic or inorganic semiconductor such as an amorphous or polycrystalline silicon material, and includes source, drain, and channel regions. The gate insulating layer **204** is formed on the active layer **203**. The gate insulating layer **204** can include any of various insulating materials.

[0067] The gate electrode **205** is formed on a predetermined area of the gate insulating layer **204**. The gate electrode **205** is connected to a gate line (not shown) through which an ON/OFF signal is applied to the TFT. The gate electrode **205** can be formed of a metal such as Au, Ag, Cu, Ni, Pt, Pd, Al, or Mo or an alloy such as Al:Nd or Mo:W, but the present invention is not limited thereto.

[0068] An insulating interlayer **206** is formed on the gate electrode **205** so as to expose the source and drain regions of the active layer **203**. The source electrode **207** and the drain electrode **208** can be formed to respectively contact the exposed source and drain regions of the active layer **203**.

[0069] A passivation layer **209** is formed to cover the TFT.

[0070] The first electrode **210** is formed on the passivation layer **209**. The passivation layer **209** is formed to expose the drain electrode **208**, and the first electrode **210** is connected to the exposed drain electrode **208**.

[0071] The first electrode **210** is a cathode and can include ITO.

[0072] A pixel defining layer **215** is formed on the first electrode **210**. The pixel defining layer **215** includes any of various insulating materials and also includes an opening **215a**. The opening **215a** is formed to correspond to the first electrode **210**. That is, the opening **215a** is formed to overlap with a predetermined area of an upper surface of the first electrode **210**.

[0073] The electron injection layer 220 is disposed on the first electrode 210. The electron injection layer 220 is disposed in the opening 215a so as not to deviate from the opening 215a of the pixel defining layer 215 and contacts the upper surface of the first electrode 210. The electron injection layer 220 includes Mg so as to improve an electron injection characteristic into the intermediate layer 230.

[0074] Also, the electron injection layer 220 is disposed to have a contact angle between about 10° and about 70° when contacting the first electrode 210.

[0075] The intermediate layer 230 is disposed on the electron injection layer 220. The intermediate layer 230 includes at least an organic emission layer (not shown). Also, similar to the above-described embodiment, the intermediate layer 230 can include at least one of an electron transport layer, a hole transport layer, and a hole injection layer, or can include none of these layers.

[0076] The second electrode 240 is disposed on the intermediate layer 230. The second electrode 240 functions as an anode. The second electrode 240 can be commonly formed across all the sub-pixels (not shown) without having an additional pattern.

[0077] When a voltage is applied through the first electrode 210 and the second electrode 240, visible light is emitted from the organic emission layer of the intermediate layer 230.

[0078] A sealing member (not shown) can be disposed on the second electrode 240. The sealing member (not shown) can be formed to protect the intermediate layer 230 and other layers against external moisture or oxygen and can be formed of glass or plastic, or alternatively, can be formed of a plurality of stacked structures each including an organic material and an inorganic material.

[0079] FIGS. 5A through 5E are cross-sectional views sequentially illustrating an embodiment of a method of manufacturing an organic light-emitting apparatus.

[0080] Referring to FIG. 5A, the first electrode 110 is formed on the substrate 101. The first electrode 110 can be formed with a predetermined pattern by using a photolithography method. A buffer layer (not shown) can be formed before forming the first electrode 110 on the substrate 101.

[0081] The first electrode 110 can be formed of a conductive material, such as, for example, ITO.

[0082] Referring to FIG. 5B, the pixel defining layer 115 is formed on the first electrode 110. The pixel defining layer 115 is formed to include the opening 115a formed with a predetermined pattern. The pixel defining layer 115 can include a high molecular material, such as, for example, polyimide.

[0083] The opening 115a is formed to correspond to the first electrode 110. The pixel defining layer 115 is formed to cover edges of the first electrode 110, and the opening 115a is formed to expose a predetermined area of the upper surface of the first electrode 110.

[0084] Referring to FIG. 5C, the exposed surface of the first electrode 110 and a surface of the pixel defining layer 115 are treated by using a surface treating material 500.

[0085] In some embodiments, the surface treating material 500 can be plasma. A surface treatment process using plasma uses oxygen or nitrogen.

[0086] Such a plasma treatment process is performed under a pressure of about 30 mmTorr to about 100 mmTorr, and a power atmosphere of about 200 W to about 1000 W. The plasma treatment process may be performed for about 30 to about 300 seconds.

[0087] The contact angle between the electron injection layer 120 and the first electrode 110, which are to be formed through the plasma surface treatment in a subsequent process, can be controlled as desired. The contact angle between the electron injection layer 120 and the first electrode 110 may be controlled to be within the range of about 10° to about 70° through the plasma treatment.

[0088] In other embodiments, the surface treating material 500 may be ultra violet (UV). A surface treatment process using UV can be performed by injecting ozone together with UV, and ozone of more than about 10% can be included. Such a UV surface treatment process is performed under a normal pressure. The UV used as the surface treating material 500 can have a wavelength of about 185 nm or about 254 nm.

[0089] The UV surface treatment process can be performed for about 10 to about 60 seconds.

[0090] The contact angle between the electron injection layer 120 and the first electrode 110, which are to be formed in a subsequent process, can be controlled as desired through the UV surface treatment. The contact angle between the electron injection layer 120 and the first electrode 110 can be controlled to be within the range of about 10° to about 70° through the UV surface treatment.

[0091] Referring to FIG. 5D, the electron injection layer 120 is formed. The electron injection layer 120 is formed to contact the upper surface of the first electrode 110. The electron injection layer 120 is disposed in the opening 115a so as not to deviate from the opening 115a of the pixel defining layer 115 and contacts the upper surface of the first electrode 110.

[0092] An additional mask is not used to form the electron injection layer 120. When the electron injection layer 120 is formed to have a pattern corresponding to that of the opening 115a, a photolithography process is not necessary.

[0093] As described above with reference to FIG. 5C, surface characteristics of the pixel defining layer 115 and the first electrode 110 change through plasma treatment or UV treatment. Thus, a contact characteristic of a contact surface between the electron injection layer 120 including Mg and the pixel defining layer 115 including a high molecular material is decreased. The electron injection layer 120 is formed only in the opening 115a of the pixel defining layer 115 instead of being formed in the entire area of the pixel defining layer 115.

[0094] A contact angle between the electron injection layer 120 including Mg and the first electrode 110 is in the range of about 10° to about 70°.

[0095] The electron injection layer 120 corresponds to the first electrode 110 formed in the opening 115a instead of corresponding to the entire pixel defining layer 115 by allowing the contact angle between the electron injection layer 120 and the first electrode 110 to be equal to or greater than about 10°. Thus, the electron injection layer 120 can be naturally formed to have a desired pattern without performing a photolithography process using an additional mask.

[0096] Also, since the contact angle between the electron injection layer 120 and the first electrode 110 is equal to or less than about 70°, contact characteristics of contact surfaces between the electron injection layer 120 and the first electrode 110 and between the intermediate layer 130 and the electron injection layer 120 are improved.

[0097] Referring to FIG. 5E, the intermediate layer 130 and the second electrode 140 are formed on the electron injection layer 120, thereby completing manufacture of the organic light-emitting apparatus 100.

[0098] The intermediate layer **130** includes at least the organic emission layer **132**. The intermediate layer **130** can also include at least one of the electron transport layer **131**, the hole transport layer **133**, and the hole injection layer **134** or can not include any layer.

[0099] The second electrode **140** is disposed on the intermediate layer **130**. The second electrode **140** functions as an anode. When the organic light-emitting apparatus **100** is a PM-type organic light-emitting apparatus, the second electrode **140** can be in the form of stripe crossing the pattern of the first electrode **110** at right angles.

[0100] A sealing member (not shown) can be disposed on the second electrode **140** so as to be opposite to a surface of the substrate **101**.

[0101] According to embodiments of the method of manufacturing the organic light-emitting apparatus **100**, the organic light-emitting apparatus **100** having an inverted structure and an improved image quality can be easily manufactured. The electron injection layer **120** can include Mg when being formed on the first electrode **110** so as to improve an electron injection characteristic from the first electrode **110** into the intermediate layer **130**. In this regard, since the electron injection layer **120** includes a metal, the electron injection layer **120** should be independently formed in each sub-pixel instead of being formed across all the sub-pixels. In some embodiments, the electron injection layer **120** can be patterned through plasma treatment or UV treatment without performing an additional process before forming the electron injection layer **120**. The electron injection layer **120** can be formed to have a desired pattern without performing an additional process, for example, a photolithography process.

[0102] The organic light-emitting apparatus and the method of manufacturing the organic light-emitting apparatus can easily improve image quality.

[0103] While the present invention has been particularly shown and described with reference to certain embodiments thereof, it will be understood by those of ordinary skill in the art that various changes in form and details can be made therein without departing from the spirit and scope of the present invention as defined by the following claims.

What is claimed is:

1. An organic light-emitting apparatus comprising:
a substrate;
a first electrode formed on the substrate, wherein the first electrode is a cathode;
an electron injection layer comprising Mg, wherein the electron injection layer is formed to contact an upper surface of the first electrode, wherein a contact angle between the electron injection layer and the first electrode is in the range of about 10° to about 70°;
an intermediate layer formed on the electron injection layer, the intermediate layer comprising an organic emission layer; and
a second electrode formed on the intermediate layer, wherein the second electrode is an anode.
2. The organic light-emitting apparatus of claim 1, wherein the first electrode comprises indium tin oxide (ITO).
3. The organic light-emitting apparatus of claim 1, further comprising a pixel defining layer disposed on the first electrode, the pixel defining layer comprising an opening, wherein the electron injection layer and the first electrode contact each other in the opening.
4. The organic light-emitting apparatus of claim 3, wherein the electron injection layer is disposed in the opening so as not to deviate from the opening.
5. The organic light-emitting apparatus of claim 3, wherein the pixel defining layer comprises a polymer material.

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专利名称(译)	有机发光显示装置及其制造方法		
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摘要(译)

有机发光装置包括：基板；形成在所述基板上的第一电极，其中所述第一电极是阴极；形成为与所述第一电极的上表面接触并包括Mg的电子注入层；形成在所述电子注入层上并包括有机发射层的中间层；以及形成在中间层上并且是阳极的第二电极。

